

Oregon Department of Environmental Quality INITIAL NOTIFICATION Plating and Polishing Operations

40 CFR 63 Subpart WWWWWW (6W)

Section 1. Facility information

Yes, I am subject to 40 CFR Part 63 Subpart 6 Air Pollutants - Area Source Standards for	W, National Emission Standards for Hazardous Plating and Polishing Operations			
Compliance Date:	010 New source:			
	(Date of startup)			
☐ No, I am NOT subject to 40 CFR Part 63 Subp	part 6W. Reason not applicable:			
If you checked the "No" box above, please	complete this Section 1 and then proceed directly to			
Section 3 of this form (skip Section 2).	1			
Company information:				
Legal Name:	Other company name (if different than legal name):			
Mailing Address:	Site Address (if different than mailing address):			
City, State, Zip Code:	City, County, Zip Code:			
Site Contact Person:				
Name:	Telephone number:			
Title:	E-mail address:			
Section 2. Identification of Affected Operation				
(1) List the operations at this facility subject to subpart 6W ^b (check all that apply):				
Electroplating (noncyanide) Continuous electroplating (noncyanide) Short-term electroplating (noncyanide) Electropolishing				

^b Important Note: These operations are affected sources under subpart 6W <u>only if/when</u> they use materials that contain or have the potential to emit Plating and Polishing metal HAP. Plating and Polishing HAP containing/potential is defined to be when the compounds of cadmium, chromium, lead, manganese, and nickel, or any of these metals in the elemental form with the exception of lead, are used or have the potential to be emitted in quantities of 0.1 percent or more, or 1.0 percent or more for elemental or compounds of manganese.

Electroforming Electroplating (cyanide) Electroless nickel Chrome conversion coating Other electroless plating/coati Thermal spraying (permanent Thermal spraying (temporary, Dry mechanical polishing	line) [in-situ)		t this facility subject to subpart 6W:
(2) List the compliance methods u	HAP	oo al	and facility subject to subpart over.
			Compliance Method(s)
Tank Process Description/ID No.	Emitted/Used (Cd, Cr, Pb, Mn, Ni)		(Check all that apply)
	(-27 - 7 - 7) /	П	Wetting agent/fume suppressant
			Vented to a control device; type:
			Tank cover
			Time limit (short-term plating only)
			Management practices
		同	Wetting agent/fume suppressant
		$ \Box$	Vented to a control device; type:
		一	Tank cover
			Time limit (short-term plating only)
		lП	Management practices
		Ħ	Wetting agent/fume suppressant
		lH	Vented to a control device; type:
			Tank cover
		lH	Time limit (short-term plating only)
		lH	Management practices
		H	Wetting agent/fume suppressant
			Vented to a control device; type:
		H	Tank cover
		lH	
		H	Time limit (short-term plating only)
		H	Management practices
			Wetting agent/fume suppressant
			Vented to a control device; type:
		ᄖ	Tank cover
			Time limit (short-term plating only)
		Щ	Management practices
			Wetting agent/fume suppressant
			Vented to a control device; type:
		Ш	Tank cover
			Time limit (short-term plating only)
			Management practices
			Wetting agent/fume suppressant
			Vented to a control device; type:

Tank cover

Tank cover

Management practices

Management practices

Time limit (short-term plating only)

Wetting agent/fume suppressant Vented to a control device; type:_

Time limit (short-term plating only)

(3) The following table lists each affected thermal spraying booth/line (temporary and permanent), and each dry mechanical polishing process subject to subpart 6W:

	<u> </u>	sasjeet to saspuze of	-
	al Spray Booth/Line or Dry	HAP Emitted/Used	Compliance Method(s)
Mecha	nnical Polishing Description/ID No.	(Cd, Cr, Pb, Mn, Ni)	(Check all that apply)
			☐ Vented to a control device;
			describe:
			Management practices (temporary
			thermal spraying only) Vented to a control device;
			describe:
			Management practices (temporary
			thermal spraying only)
			☐ Vented to a control device;
			describe:
			Management practices (temporary
			thermal spraying only) Vented to a control device;
			describe:
			Management practices (temporary
			thermal spraying only)
(4)	The following applicable managem	ent practices are used a	at this facility, as practicable:
	Minimize both agitation when remove	ing any parts processed i	in the tank, as practicable except when
Ш	necessary to meet part quality require		in the tank, as practicable except when
			practicable, by extending drip time when
			as drip shields); or withdrawing parts
	slowly from the tank, as practicable.	with compact (with interpretation)	t us unip smotos), or windrawing points
		and parts to minimize d	ragout of bath solution (such as by using
			w-through holes to allow the tank solution
	to drip back into the tank), as practical	0 01	
	Use tank covers, if already owned an		, whenever practicable.
	Minimize or reduce heating of process	ss tanks, as practicable (e	e.g., when doing so would not interrupt
	production or adversely affect part qu	ıality).	
	Perform regular repair, maintenance,	and preventive maintena	ance of racks, barrels, and other
	equipment associated with affected se	•	
			or quick recovery of dropped parts, use of
			rts to be plated, and thorough rinsing of
	pre-treated parts to be plated, as prac-		
	± •	s, and chemical and other	r bath ingredient concentrations in the
	tanks, as practicable.	1 1 .	
		such as regular sweeping	g or vacuuming, if needed, and periodic
	washdowns, as practicable.	a ag pr acticable	
H	Minimize spills and overflow of tank Use squeegee rolls in continuous or r		as practicable
H	Perform regular inspections to identify	<u> </u>	<u>-</u>
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Section 3. Certification

I certify, under penalty of law that the information on this notification form is true, accurate and complete to the best of my knowledge.				
(Signature)	(Date)			
(Name/title)	(Telephone No.)			

Section 4. Submittal

Mail or fax original forms to:

Rebecca Hillwig, DEQ Air Quality Division 811 SW Sixth Ave Portland, OR 97204-1390

Fax: 503-229-5675